Title:

Growth and characterization of InSe thin films on GaAs(111)B and Si(111)

Abstract Body:

Urgent societal and environmental needs have sparked searches for high-mobility 2D materials with sizeable bandgap and decent stability under ambient conditions for use in ultra-low power, ultra-high performance field effect transistors. With a carrier mobility exceeding 1000 cm²/Vs, small electron effective mass, flat electronic band dispersions, excellent optoelectronic, possible ferroelectric properties and a close-to-ideal solar spectrum matched bulk bandgap of 1.26 eV, InSe shows high potential for future use in electronics. Due to the layered nature, and the many members of different polytypes in the InSe materials family, intriguing confinement phenomena and exotic electron-hole coupling mechanisms tunable by the number of single layers add to the potential wealth of properties in InSe.

In this study, InSe thin films were grown by MBE on GaAs(111)B and Si(111). The presence of many InSe phases required a systematic mapping of the growth parameters to identify conditions for single-phase, single-polytype, and single-crystal growth. Through structural characterization in- and ex-situ using reflection high-energy electron and X-ray diffraction, growth conditions for solely gamma-phase, crystalline InSe films were found. Although the structural properties of the films presented nearly unchanged over a small window of growth conditions, the film morphology was seen to sensitively depend on the Se:In flux ratio. Raman spectroscopy confirmed the phase and polytype assignment deduced from large-area structural characterization.

Microstructure analysis, however, revealed a high degree of structural defects in the films. Nano-scale domains of varying single layer stacking sequences, high-angle rotational domains as well as single layers of unusual bonding configuration resulting in a novel InSe polymorph were found in the films. The total number of defects and the general locations of the new polymorph varied in films across GaAs and Si. The highest structural homogeneity was found for InSe films grown on Si.

Density functional theory calculations for a representative selection of the experimentally observed defects confirmed that most defects, including the novel polymorph have formation energies at or below the thermal budget of the MBE synthesis process. Although the bandgaps of all InSe polytypes and polymorphs possess comparable values, large differences were found in their relative offsets. Due to the random distribution of polytypes and polymorphs in the film, our study suggests a high degree of electronic disorder in these films. Electrical transport showed a variable-range hopping-like behavior supporting the hypothesis of electronic disorder.

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